

Direct Write Lithography – fast and flexible prototyping without photo masks

Christian PIES - *Heidelberg Instruments Mikrotechnik, Germany*

Maskless lithography technology has become firmly established in research labs worldwide as well as in many small to mid-volume micro fabrication facilities. Application areas include MEMS, microfluidics, micro-optics, sensors, electronic components and many more. This presentation will give you an insight into our maskless lithography technology with emphasis on our DWL series and the maskless aligner (MLA) series.